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### Activities for phenol formation using Cu catalysts supported on Al<sub>2</sub>O<sub>3</sub> in the liquid-phase oxidation of benzene in aqueous solvent with high acetic acid concentration

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#### Abstract

The liquid-phase oxidation of benzene to phenol using a Cu catalyst supported on  $Al_2O_3$  was studied at 303 K in an aqueous solvent with a variety of concentrations of acetic acid. Gaseous  $O_2$  and ascorbic acid were utilized as an oxidant and a reducing reagent, respectively. An aqueous solvent with more than around 70–80 vol.% acetic acid concentration was confirmed to cause a sharp apparent decrease in the Cu leaching from a Cu catalyst (Cu/Al<sub>2</sub>O<sub>3</sub>) impregnated on  $Al_2O_3$ , as well as a CuO-Al<sub>2</sub>O<sub>3</sub> catalyst prepared by a co-precipitation method reported previously, during the benzene oxidation, keeping the yield of phenol comparatively high. The apparent Cu leaching was largely inhibited in an aqueous solvent with high acetic acid concentration in comparison with a solvent of low acetic acid concentration, irrespective of the presence of benzene and/or ascorbic acid. The influences of both the Cu amount supported on the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst and the amount of ascorbic acid on the yield of phenol were investigated in the aqueous solvents with acetic acid concentrations of both 5.7 and 80 vol.%. The Cu/Al<sub>2</sub>O<sub>3</sub> catalyst in the aqueous acetic acid solvent was deactivated in the comparatively initial stage of the oxidation of benzene. The catalytic activity of the used Cu supported catalyst for phenol formation was almost completely recovered by calcining the catalyst at 773 K. The amount of the deactivated Cu species based on a XRD peak at  $2\theta = 23^{\circ}$  in the used Cu/Al<sub>2</sub>O<sub>3</sub> catalyst was found to have a correlation with the yield of phenol.

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#### 1. Introduction

More than 90% of phenol, one of the important chemicals in the practical fields of resin, fiber, and medicine, has been produced by a cumene method [1,2]. The disadvantage of this method is the inclusion of a three-step process, although the selectivity in the each step is quiet high, and the yield of a by-product, acetone, in addition to phenol formation [3]. Phenol production by the toluene method, which includes a two-step process and produces no by-product such as acetone, has been performed [4] in a few practical chemical plants. A one-step production of phenol through the direct oxygenation of benzene has so far been attempted using various catalytic systems by many researchers. The practical development of the one-step production of phenol will have advantages in cost reduction and energy saving [3]. Phenol formation via the direct oxygenation of benzene formally includes insertion of an oxygen atom between the C-H bond of benzene. Because of the high stability of benzene, the direct oxygenation of benzene to form phenol has been thought to be one of the most difficult oxidation reactions but also to be one of the most challenging oxidation reactions from the point of view of organic synthetic chemistry. A direct hydroxylation of benzene has been reported using an Fe<sup>2+</sup>-H<sub>2</sub>O<sub>2</sub> system (Fenton's reagent) by Norman and co-workers [5]. An Fe<sup>3+</sup>-H<sub>2</sub>O<sub>2</sub>-catechol system (Hamilton reagent) has also been utilized for the oxygenation of benzene [6]. The oxygenation of benzene using molecular oxygen, which will be less expensive and more easily handled, as an oxidant instead of hydrogen peroxide, has been attempted [7]. More recently, noble metal-vanadium (V) oxide catalysts supported on silica have been reported

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to be active for benzene oxidation to phenol in the presence of both gaseous oxygen and hydrogen under a pressurized atmosphere [8,9]. The benzene oxidation to phenol has also been attempted using an EuCl<sub>3</sub>-TiO(acac)<sub>2</sub> catalyst with Zn as a reducing reagent [10] or using a partially exchanged heteropoly acid as a catalyst [11–13]. Phenol formation by the direct hydroxylation of benzene with both oxygen and hydrogen on platinum catalyst supported on SiO2 has been reported to be accelerated when acetylacetonate of vanadium was added to the reaction medium [14]. The reductive oxidation of benzene to phenol with both  $O_2$  and  $H_2$  has been reported using the catalytic palladium membrane [15,16]. We have reported the liquid-phase oxidation of benzene to phenol catalyzed by Cu catalysts [17-19] supported on various oxides including zeolites, MCM-41 and a CuO-Al<sub>2</sub>O<sub>3</sub> catalyst [20] prepared by a co-precipitation method using gaseous oxygen as an oxidant and ascorbic acid as a reducing reagent. Vanadium catalysts [21,22] supported on SiO<sub>2</sub> and Al<sub>2</sub>O<sub>3</sub>, instead of the supported Cu catalysts, have also been utilized for the benzene oxidation using gaseous oxygen as an oxidant and ascorbic acid as a reducing reagent. On the way to conduct our recent study on the liquid-phase benzene oxidation to phenol using the Cu catalysts (CuO-Al<sub>2</sub>O<sub>3</sub>) prepared by a co-precipitation method, an aqueous solvent with high acetic acid concentration has been found [20] to have a specific character for apparently inhibiting the apparent Cu leaching from the CuO-Al<sub>2</sub>O<sub>3</sub> catalyst, together with a higher yield of phenol, during the benzene oxidation. Supported V catalysts in the aqueous solvent with high acetic acid were also reported [22] to have high catalytic activity for phenol formation, though the V leaching was not decreased, in the benzene oxidation.

In this study, we have mainly investigated the catalytic behavior of the Cu catalysts impregnated on Al<sub>2</sub>O<sub>3</sub> (Cu/Al<sub>2</sub>O<sub>3</sub>) in place of the CuO-Al<sub>2</sub>O<sub>3</sub> catalyst prepared by a co-precipitation method reported previously [20], in aqueous solvent with high acetic acid concentration on the benzene oxidation to phenol. The main aim of this study is to elucidate the influence of the Cu species, ascorbic acid, and the solvent on the activation of oxygen molecule in the oxygenation of benzene to phenol. The amount of the Cu species of a XRD peak observed at  $2\theta = 23^{\circ}$  in the used Cu/Al<sub>2</sub>O<sub>3</sub> catalyst had a correlation with the yield of phenol.

#### 2. Experimental

#### 2.1. Catalyst preparation

The Cu catalysts (Cu/oxide support) impregnated on  $Al_2O_3$  (JRC-AlO<sub>6</sub>), SiO<sub>2</sub> (JRC-SiO<sub>8</sub>), TiO<sub>2</sub> (JRC-TiO<sub>2</sub>), SiO<sub>2</sub>-Al<sub>2</sub>O<sub>3</sub> (Nikki), MCM-41 (synthesized in this lab [23,24]), and HMCM-41 (synthesized in this lab [23,24]) were prepared by a conventional impregnation method using an aqueous solution of the prescribed concentration of Cu(CH<sub>3</sub>COO)<sub>2</sub>. The resulting impregnated Cu catalysts

were dried at 393 K overnight and calcined at 773 K for 5 h in an air flow. The co-precipitated Cu catalyst (CuO-Al<sub>2</sub>O<sub>3</sub>) was prepared as follows: into an aqueous solution in which Cu(NO<sub>3</sub>)<sub>2</sub>·3H<sub>2</sub>O (Nacarai Tesque, guaranteed reagent, 0.57 g) and Al(NO<sub>3</sub>)<sub>3</sub> (Nacarai Tesque, guaranteed reagent, 35.69 g) were homogeneously dissolved,  $500 \text{ cm}^3$  of 1N aqueous Na<sub>2</sub>CO<sub>3</sub> solution was added, and the mixture was stirred at 353 K for 3 h. The resulting precipitate was filtered-off under vacuum, washed with deionized water until the filtrate changed to pH 7, dried at 393 K overnight, and calcined at 623 K for 3 h in an air flow. The reduced CuO-Al<sub>2</sub>O<sub>3</sub> catalyst was prepared by reducing at 553 K for 3h under a H<sub>2</sub> flow. The amount of Cu on the CuO-Al<sub>2</sub>O<sub>3</sub> catalyst was quantitatively measured by an atomic absorption spectrometer (Shimazu Type AA-630-01) after homogeneously dissolving the catalyst by adding a few drop of hydrogen fluoride (Hashimoto Chemical, 47% content, guaranteed reagent). The (Zn-Cu)/Al<sub>2</sub>O<sub>3</sub> catalyst, the Cu and Zn of which were co-impregnated on an Al<sub>2</sub>O<sub>3</sub> support was prepared using both  $Cu(CH_3COO)_2$  and  $Zn(CH_3COO)_2$ (Nacarai Tesque, guaranteed reagent) followed by drying at 393 K overnight and calcining at 773 K for 5 h in flowing air. The reduced (Zn-Cu)/Al<sub>2</sub>O<sub>3</sub> catalyst was prepared by reducing at 553 K for 5 h in flowing H<sub>2</sub>. A Rb-added Cu/Al<sub>2</sub>O<sub>3</sub> catalyst (Rb/Cu/Al<sub>2</sub>O<sub>3</sub>) was prepared by impregnating CH<sub>3</sub>COORb (Nacarai Tesque, guaranteed reagent), drying at 393 K overnight, and calcining at 773 K for 5 h in flowing air.

## 2.2. Liquid-phase oxidation of benzene with the supported Cu catalysts

Benzene (Nacarai Tesque, guaranteed reagent) and acetic acid (Nacarai Tesque, guaranteed reagent) were used without further purification. Into a  $50 \text{ cm}^3$  glass reactor,  $2 \text{ cm}^3$ of benzene (22.5 mmol), 20 cm<sup>3</sup> of aqueous acetic acid (80 vol.%), 0.4 g catalyst, and the prescribed amount of a reductant were added. The reaction mixture was stirred magnetically at 303 K for 24 h under 0.1 MPa O<sub>2</sub> atmosphere. After adding 20 cm<sup>3</sup> of 2-propanol as an internal standard to the reaction solution, the reaction solution was separated from the solid catalyst by centrifugation. (2-Propanol was confirmed not to convert to acetone during the treatment.) The analyses of the oxidation product were performed at 453 K using a GLC (Shimazu Type GC-8A) with a 3 m stainless column packed with Silicon OV-17 and a 1.5 m stainless column packed with 5% Thermon-3000 on SHIN-CARBON A. The quantitative analyses of the amount of the apparent Cu leaching were carried out by measuring the Cu amount dissolved in the filtrate using atomic absorption equipment (Shimazu type AA-6200) after separating the solid catalyst from the reaction solution by centrifugation.

#### 2.3. XRD measurement of supported Cu catalysts

The XRD patterns of both a fresh supported Cu catalyst and a used counterpart were measured at room temperature using Rigaku Type Ultima<sup>+</sup> XRD equipment with a Cu K $\alpha$  source. The used supported Cu catalyst separated through centrifugation was washed with acetone and either dried at around 383 K overnight or calcined at 773 K for 5 h in flowing air and subjected to XRD measurement.

#### 2.4. Measurement of UV-Vis spectra

To investigate the generation of hydrogen peroxide, the UV-Vis absorption spectra of the aqueous solution including  $Cu(CH_3COO)_2$  and ascorbic acid were measured at room temperature under air atmosphere using an electronic absorption spectrophotometer (Shimazu UV-240).

## 2.5. Liquid-phase adsorptions of benzene and phenol on $Al_2O_3$ support and the Cu/Al\_2O\_3 catalysts

A 1.0 g sample of the Al<sub>2</sub>O<sub>3</sub> support or a Cu/Al<sub>2</sub>O<sub>3</sub> catalyst was added to 20 cm<sup>3</sup> of aqueous solution of 80 vol.% acetic acid including 2 cm<sup>3</sup> of benzene or phenol. The whole system was stirred magnetically at 303 K for 24 h under N<sub>2</sub> atmosphere (0.1 MPa). After stirring, the benzene or phenol remaining in the solution was analyzed by GLC to quantitatively analyze the amount of benzene or phenol adsorbed on the Al<sub>2</sub>O<sub>3</sub> support or the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst.

#### 2.6. ESR spectra of the supported Cu catalysts

The ESR spectra of both the fresh and the used  $Cu/Al_2O_3$  catalysts in a quartz cell were measured at room temperature using an ESR spectrometer (JES-TE-300). The fresh catalyst was degassed at 473 K for 2 h before ESR measurement. The used catalyst isolated centrifugally from the reaction solution was washed with acetone, dried at 373 K under  $N_2$  flow, and degassed at 473 K for 2 h before the ESR measurement.

#### 3. Results and discussion

#### 3.1. Influences of both the supported Cu catalysts prepared under various conditions and the reaction conditions on the liquid-phase oxidation of benzene to phenol

The time dependence of both the yield of phenol and the percentage of Cu leaching was investigated using the co-precipitated Cu catalyst (CuO-Al<sub>2</sub>O<sub>3</sub>, Cu = 1.5 wt.%) in aqueous solvents with acetic acid concentrations of both 5.7 and 80 vol.% (Fig. 1(A)). The time dependence of the yield of phenol using the Cu catalyst impregnated on Al<sub>2</sub>O<sub>3</sub> (Cu/Al<sub>2</sub>O<sub>3</sub>, Cu = 2 wt.%) in the aqueous solvent with 80 vol.% acetic acid is also illustrated in Fig. 1(B). No other products except phenol were detected under the reaction conditions studied in this report. The yields of phenol in both solvents increased with the reaction time up to around 2–3 h, but the extent of the increase in the phenol yield greatly declined beyond reaction times of around



Fig. 1. Relationship of both yield of phenol and Cu leaching vs. reaction time. (A) Catalyst: 0.4 g of CuO-Al<sub>2</sub>O<sub>3</sub> (Cu = 1.5 wt.%), (B) catalyst: 0.4 g of Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 2 wt.%); ascorbic acid: 4 mmol; O<sub>2</sub>: 0.1 MPa; reaction temperature: 303 K. ( $\bullet$ ), ( $\blacksquare$ ) 20 cm<sup>3</sup> of aqueous solvent of 80 vol.% acetic acid; ( $\bigcirc$ ), ( $\square$ ) 20 cm<sup>3</sup> of aqueous solvent of 5.7 vol.% acetic acid; ( $\bullet$ ), ( $\bigcirc$ ) yield of phenol; ( $\blacksquare$ ), ( $\square$ ) percentage of Cu leaching.

5 h, irrespective of the supported Cu catalysts. The yield of phenol over the CuO-Al<sub>2</sub>O<sub>3</sub> catalyst using the aqueous solvent with the concentration of 80 vol.% acetic acid was higher than that using the counterpart with 5.7 vol.% acetic acid. The time dependence of both the percentages of the apparent Cu leaching showed behavior similar to those of both the yields of phenol. However, it must be noted that the apparent Cu leaching in the aqueous solvent with 80 vol.% acetic acid became remarkably lower than that in the aqueous solvent containing 5.7 vol.% acetic acid.

Fig. 2 illustrates the influence of the volumetric concentration of acetic acid in the aqueous acetic acid solvent on the yield of phenol at the reaction time of 24 h and the percentage of the apparent Cu leaching in the oxidation of benzene catalyzed by both the CuO-Al<sub>2</sub>O<sub>3</sub> (Fig. 2(A)) and the Cu/Al<sub>2</sub>O<sub>3</sub> (Fig. 2(B)). The yield of phenol increased with the



Fig. 2. Dependence of the concentration of acetic acid on both the yield of phenol and the Cu leaching. (A) Catalyst: 0.4 g of CuO-Al<sub>2</sub>O<sub>3</sub> (Cu = 1.5 wt.%), (B) catalyst: 0.4 g of Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 2 wt.%); benzene: 22.5 mmol; solvent: 20 cm<sup>3</sup> of aqueous acetic acid; O<sub>2</sub>: 0.1 MPa; ascorbic acid: 4 mmol; reaction temperature: 303 K; reaction time: 24 h. ( $\bullet$ ) Yield of phenol, ( $\Box$ ) percentage of Cu leaching.

increase in the acetic acid concentration, but further increase in the acetic acid concentration inversely caused a decrease in the phenol yield and passed through a maximum value at a concentration of around 70 vol.%. The yield of phenol obtained in ca. 98 vol.% acetic acid solvent was somewhat lower than that in pure H<sub>2</sub>O. The reason that the yield of phenol has an optimum value for the concentration of acetic acid will be interpreted by the following two factors. The reduction of Cu<sup>2+</sup> to Cu<sup>+</sup>, of which the reduced Cu species are indispensable for phenol formation [17–20], by ascorbic acid will be inhibited in the strong acid medium [25]. On the other hand, the production of  $H_2O_2$  by the reduction of  $O_2$  with the Cu<sup>+</sup> will be promoted in acid medium, and the produced H<sub>2</sub>O<sub>2</sub> can be stably present in the acid medium [26]. Thus, the trade-off between the ease of the reduction of Cu<sup>2+</sup> to Cu<sup>+</sup>, and the effective production and the stability of the produced H<sub>2</sub>O<sub>2</sub> might result in an optimum aqueous solvent with an acetic acid concentration of around 70 vol.%. The percentage of the apparent Cu leaching remained almost constant (around 30% for CuO-Al<sub>2</sub>O<sub>3</sub> and 40 vol.% for Cu/Al<sub>2</sub>O<sub>3</sub>) up to acetic acid concentrations of ca. 30-40 vol.%. Further increase in the acetic acid concentration caused a gradual decrease in the percentage of apparent Cu leaching. Surprisingly, acetic acid concentrations of more than around 40-60 vol.% caused a sharp decrease in the percentage of apparent Cu leaching. On the other hand, the yield of phenol hardly decreased up to acetic acid concentrations of around 80 vol.% as illustrated in Fig. 2(A) and (B). The aqueous solvent containing high acetic acid was thus confirmed to inhibit the apparent Cu leaching from the Cu catalyst (Cu/Al<sub>2</sub>O<sub>3</sub>) impregnated on Al<sub>2</sub>O<sub>3</sub>, as well as the CuO-Al<sub>2</sub>O<sub>3</sub> catalyst reported previously [20], keeping the phenol yield comparatively high.

Table 1 indicates the yield of phenol and the percentage of apparent Cu leaching for the Cu catalysts impregnated on various oxide supports using aqueous solvents of both 20 and 80 vol.% acetic acid. Only phenol was detected as the

Table 1

Influence of oxide supports on the yield of phenol and the percentage of apparent Cu leaching using the aqueous solvent of both 20 and 80 vol.% acetic acids<sup>a</sup>

Catalyst	Acetic acid (20 vol.%)		Acetic acid (80 vol.%)	
	Yield of phenol (%)	Apparent Cu leaching (%)	Yield of phenol (%)	Apparent Cu leaching (%)
Cu/SiO <sub>2</sub>	0.9	57.1	1.4	1.8
Cu/TiO <sub>2</sub>	0.4	42.3	0.6	1.0
Cu/Al <sub>2</sub> O <sub>3</sub>	1.4	73.8	2.5	1.7
Cu/SiO <sub>2</sub> -Al <sub>2</sub> O <sub>3</sub>	1.0	68.5	2.1	2.3
Cu/MCM-41 (Si/Al = $\infty$ )	1.1	64.5	1.6	2.1
Cu/MCM-41 (Si/Al = $108$ )	1.3	69.2	1.7	2.1
Cu/MCM-41 (Si/Al = 69)	1.6	58.3	2.1	3.2
Cu/MCM-41 (Si/Al = 26)	1.5	62.2	2.5	3.1

<sup>a</sup> *Reaction conditions*: Cu content, 2 wt.%; benzene, 22.5 mmol; solvent, aqueous acetic acid, 20 cm<sup>3</sup>; O<sub>2</sub>, 0.1 MPa; ascorbic acid, 4 mmol; reaction temperature, 303 K; reaction time, 24 h.

oxidation product for all the supported Cu catalytic systems studied here. The yield of phenol using the aqueous solvent of 80 vol.% acetic acid was higher than that using 20 vol.% acetic acid regardless of the oxide supports. Once again, the percentages of apparent Cu leaching in the aqueous solvent of 80 vol.% acetic acid considerably declined in comparison with those in 20 vol.% acetic acid. Thus, the aqueous solvent with a high acetic acid concentration of around 80 vol.% was confirmed to be eligible to both phenol production and the inhibition of apparent Cu leaching. The aqueous acetic acid solvent with the acetic acid concentration of around 80 vol.% was thus found to be an optimum solvent maintaining both a comparatively high yield of phenol and a low level of apparent Cu leaching.

The dependence of the amount of the supported Cu on the yield of phenol was investigated using the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst in aqueous solvent of an acetic acid concentration of 80 vol.% (Fig. 3). The yield of phenol sharply increased with the increase in the amount of the supported Cu up to around 3 wt.%, but further increase in the Cu amount inversely caused a decline in the yield of phenol. Too high an amount of the supported Cu may not function effectively for phenol formation because of the aggregation of Cu species on the Al<sub>2</sub>O<sub>3</sub> support. In fact, the ESR spectrum of the used Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 20 wt.%) catalyst was characteristic of aggregated Cu species [27] (not depicted). The percentage of apparent Cu leaching remained at low values regardless of the amount of the supported Cu.

The influence of the calcination temperature of the  $Cu/Al_2O_3$  catalyst on the constant amount of the supported Cu of 2 wt.% is illustrated in Fig. 4. The calcination temperatures in the range of 573–973 K caused little change in the yield of phenol. However, the apparent Cu leaching



Fig. 4. Influence of calcination temperature on both the yield of phenol and percentage of Cu leaching. Catalyst: 0.4 g of Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 2 wt.%); benzene: 22.5 mmol; solvent:  $20 \text{ cm}^3$  of aqueous 80 vol.% acetic acid; ascorbic acid: 4 mmol; reaction temperature: 303 K; reaction time: 24 h. (•) Yield of phenol, ( $\Box$ ) percentage of Cu leaching.

was moderately inhibited by calcining the catalyst at higher temperatures. The yield of phenol and the percentage of apparent Cu leaching for the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst only dried at 393 K overnight were 2.3 and 6.8%, respectively.

The influence of the amount of ascorbic acid as a reducing reagent on the yield of phenol was investigated using both the Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 1.5 wt.%) and the CuO-Al<sub>2</sub>O<sub>3</sub> (Cu = 1.5 wt.%) catalysts (Fig. 5) in the aqueous solvent with 80 vol.% acetic acid. The result [20] of the CuO-Al<sub>2</sub>O<sub>3</sub> (Cu = 3.0 wt.%) catalyst in the aqueous solvent with 5.7 vol.%





Fig. 3. Dependence of the amount of supported Cu on the yield of phenol and the percentage of Cu leaching. Catalyst: 0.5 g of Cu/Al<sub>2</sub>O<sub>3</sub>; benzene: 22.5 mmol; solvent:  $20 \text{ cm}^3$  of aqueous 80 vol.% acetic acid; O<sub>2</sub>: 0.1 MPa; ascorbic acid: 4 mmol; reaction temperature: 303 K; reaction time: 24 h.

Fig. 5. Influence of amount of ascorbic acid on the yield of phenol. ( $\bullet$ ) Cu/Al<sub>2</sub>O<sub>3</sub> catalyst (Cu = 2 wt.%) in 20 cm<sup>3</sup> of aqueous 80 vol.% acetic acid, ( $\blacksquare$ ) CuO-Al<sub>2</sub>O<sub>3</sub> (Cu = 1.5 wt.%) in 20 cm<sup>3</sup> of aqueous 80 vol.% acetic acid, ( $\square$ ) CuO-Al<sub>2</sub>O<sub>3</sub> (Cu = 3 wt.%) in 20 cm<sup>3</sup> of aqueous 5.7 vol.% acetic acid ([16]). Catalyst: 0.4 g of Cu/Al<sub>2</sub>O<sub>3</sub>; benzene: 22.5 mmol; reaction temperature: 303 K; reaction time: 24 h for ( $\bullet$ ) and ( $\blacksquare$ ), 5 h for ( $\square$ ).

acetic acid is also plotted as a reference. The CuO-Al<sub>2</sub>O<sub>3</sub> catalyst in the aqueous solvent with 80 vol.% acetic acid had higher catalytic activity than that in the solvent with 5.7 vol.% acetic acid, in spite of the fact that the Cu content of the latter catalyst was twice that of the former. The yield of phenol increased with the increase in the amount of ascorbic acid, but too large an amount of ascorbic acid tended to inversely decrease the yield of phenol on both catalysts. The excess amount of ascorbic acid is suggested to decompose  $H_2O_2$  produced during the benzene oxidation, rather than being effectively available for phenol formation. To ascertain the behavior of ascorbic acid toward H<sub>2</sub>O<sub>2</sub>, the variation in the electronic absorption spectra of aqueous H<sub>2</sub>O<sub>2</sub>  $(8.8 \times 10^{-3} \text{ mol/l})$  solution by adding an aqueous solution of ascorbic acid  $(8.0 \times 10^{-4} \text{ mol/l})$  was observed. The peak at around 200 nm based on H<sub>2</sub>O<sub>2</sub>, together with the peak intensity of the ascorbic acid at 260 nm, was confirmed to decrease with time. The stability of  $H_2O_2$ , formed during the oxidation of benzene catalyzed by the supported Cu catalysts in an acid medium may be the reason why the maximum value of the phenol yield shifted to a higher amount of ascorbic acid in the aqueous solvent with 80 vol.% acetic acid concentration than that with 5.7 vol.% acetic acid.

The influence of rubidium (as an oxide) added to the Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 2 wt.%) catalyst on the benzene oxidation to phenol was investigated using the Rb/Cu/Al<sub>2</sub>O<sub>3</sub> catalysts with the added Rb/Cu atomic ratios of 1, 5, and 10. The Rb/Cu/Al<sub>2</sub>O<sub>3</sub> catalyst with the added Rb/Cu ratio of 1 slightly promoted the phenol formation (the phenol yields of the Cu/Al<sub>2</sub>O<sub>3</sub> and the Rb/Cu/Al<sub>2</sub>O<sub>3</sub> catalysts were 2.5 and 2.75%, respectively) but the catalysts with the ratios of 5 and 10 inversely inhibited the phenol formation (both the phenol yields were 2.3%). The zinc co-impregnated Cu/Al<sub>2</sub>O<sub>3</sub> catalyst [(Zn-Cu)/Al<sub>2</sub>O<sub>3</sub>] was attempted as a catalyst for the liquid-phase benzene oxidation to investigate if the added zinc metal functions as a reducing reagent, but the impregnated Zn had no effect as a reducing reagent for the phenol formation.

#### 3.2. Apparent Cu leaching from the supported Cu catalyst in the aqueous solvents with concentrations of both high and low acetic acid

Whenever a supported metal catalyst is utilized in a liquid-phase reaction, a concomitant concern is the leaching of the supported metal ion into the reaction solution during the catalytic reaction. The use of an aqueous solvent with acetic acid of high concentrations was found to considerably inhibit the apparent leaching of Cu (Fig. 2). The Cu species leached into the reaction solution from the catalyst will be reduced to Cu<sup>+</sup> ions during the benzene oxidation in the presence of ascorbic acid [17–20], the reduced Cu<sup>+</sup> species are insoluble in the reaction solution and precipitate during the benzene oxidation, the sharp decline in the precentage of

#### Table 2

Percentage of apparent Cu leaching from the CuO-Al $_2O_3$  catalyst in various solutions<sup>a</sup>

Concentration of	f Only solvent (%)	Solution			
acetic acid in solvent (vol.%)		Benzene (%)	Ascorbic acid (%)	Benzene + ascorbic acid (%)	
5.7	65.3	60.2	33.0	31.0	
80	6.3	4.4	1.9	1.9	

<sup>a</sup> Reaction conditions: catalyst, CuO-Al<sub>2</sub>O<sub>3</sub> (Cu = 1.5 wt.%), 0.4 g; solvent, 20 cm<sup>3</sup> of aqueous acetic acid; benzene, 22.5 mmol (2 cm<sup>3</sup>); ascorbic acid, 4 mmol; temperature, 303 K; treating time, 24 h; O<sub>2</sub>, 0.1 MPa.

the Cu leaching at acetic acid concentrations of more than around 40-60 vol.% observed in Fig. 2 may be only an apparent value, because the percentages of the Cu leaching were obtained by measuring the homogeneous Cu species soluble in the reaction solution. The influence of ascorbic acid and/or benzene present in the aqueous acetic acid solution on the apparent Cu leaching of the CuO-Al<sub>2</sub>O<sub>3</sub> catalyst was investigated using aqueous solutions with acetic acid concentrations of both 5.7 and 8 vol.% (Table 2), where the percentage of the apparent Cu leaching was measured after stirring for 24 h at 303 K under each condition described in Table 1. The percentage of apparent Cu leaching in aqueous acetic acid solvent containing no ascorbic acid was considerably different for the concentrations of acetic acid of 5.7 and 80 vol.%. Thus, the aqueous solvent with acetic acid of a high concentration (80 vol.%) caused a much lower Cu leaching than that with acetic acid of a low concentration (5.7 vol.%). The percentages of the apparent Cu leaching in the presence of only ascorbic acid using both the 5.7 and 80 vol.% acetic acid concentrations were very similar to those obtained in the solution including both benzene and ascorbic acid (in which solution the benzene oxidation proceeds). The apparent Cu leaching in the latter two systems containing ascorbic acid were lower than those in the former two systems not containing ascorbic acid, irrespective of the acetic acid concentration of 5.7 and 80 vol.%. The difference in the Cu leaching between both the systems containing and not containing ascorbic acid will be due to the contribution of the Cu<sup>+</sup> species reduced by ascorbic acid to the apparent decline of the percentage of the Cu leaching. The result that the apparent Cu leaching in the aqueous solution with acetic acid of high concentrations was thus considerably lower than that in acetic acid of low concentrations, irrespective of the presence of ascorbic acid, indicates that the aqueous solvent with high acetic acid concentration can intrinsically inhibit the Cu leaching, though the contribution of the insoluble Cu<sup>+</sup> reduced by ascorbic acid cannot be ignored as described previously.

## 3.3. Deactivation of the $Cu/Al_2O_3$ catalyst and its regeneration

The reuse of the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst was attempted after the used catalyst washed with acetone was either only dried



Fig. 6. Reuse of the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst in the oxidation of benzene. Catalyst: 0.4 g of Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 2 wt.%); benzene: 22.5 mmol; solvent: 20 cm<sup>3</sup> of aqueous 80 vol.% acetic acid; ascorbic acid: 4 mmol; reaction temperature: 303 K; reaction time: 24 h. (A) Reuse of the catalyst after drying at 393 K overnight, (B) reuse of the catalyst after calcining at 773 K for 5 h in flowing air.

at 393 K overnight or calcined at 773 K for 5 h (Fig. 6). The catalytic activity of the reused catalyst treated only by drying largely decreased with repeated use (Fig. 6(A)). On the other hand, the yield of phenol obtained by the third reaction was almost similar to that of the first one when the used catalyst was dried at 393 K followed by calcination at 773 K (Fig. 6(B)). The apparent Cu leaching was inhibited with repeated usage of the catalyst, regardless of the treatment method for the used catalyst.

As described previously, the yield of phenol leveled-off at a reaction time of around 5–10 h and hardly increased with a further increase in the reaction time, irrespective of the supported Cu catalysts (Fig. 1). Based on these results, the adsorption of the produced phenol on the catalyst surface will be considered one of the causes of deactivation. However, the liquid-phase adsorption experiment of phenol confirmed that the phenol hardly adsorbed on either the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst or Al<sub>2</sub>O<sub>3</sub> support under conditions similar to the benzene oxidation.

To investigate another cause of the deactivation, XRD measurements of both the fresh and the used  $Cu/Al_2O_3$  (Cu



Fig. 7. XRD patterns of  $Cu/Al_2O_3$  catalysts. (a) Fresh  $Cu/Al_2O_3$  catalyst, (b) used  $Cu/Al_2O_3$  catalyst, (c) used  $Cu/Al_2O_3$  (b) calcined at 773 K for 5 h in flowing air.

= 20 wt.%) catalysts were carried out (Fig. 7). The intensity of the XRD pattern based on CuO of the used catalyst became lower than that of the fresh one. The ESR spectra (not illustrated) of both the fresh and the used catalysts showed that the ESR peaks based on  $Cu^{2+}$  of the latter catalyst became lower than that of the former, in accordance with the XRD data. However, a marked difference in both the XRD patterns is the appearance of a sharp peak at  $2\theta = 23^{\circ}$  in the used catalyst (Fig. 7(b)). The new XRD peak was not identical with those of Cu powder, Cu<sub>2</sub>O, CuO, copper(II) acetate, copper(II) hydroxide, and copper(II) carbonate. The Cu precipitate produced from a mixture of copper(II) acetate and ascorbic acid in aqueous acetic acid of 80 vol.% showed an XRD peak at  $2\theta = 23^{\circ}$  (Fig. 8(a)) that was exactly the same as that which appeared in the used Cu/Al<sub>2</sub>O<sub>3</sub> catalyst (Fig. 8(b)). Thus, the Cu species based on the XRD peak



Fig. 8. XRD patterns of the precipitate and the  $Cu/Al_2O_3$  catalyst. (a) Cu precipitate formed from the mixture of copper acetate and ascorbic acid in acetic acid, (b) used  $Cu/Al_2O_3$  (same as in Fig. 7(b)).

at  $2\theta = 23^{\circ}$  will be due to the reduced Cu species. We are now exploring the identification of the Cu species based on the XRD peak at  $2\theta = 23^{\circ}$  and will report the results in the near future, though we have no knowledge yet of a definite formula for the Cu precipitate. The calcination of the used Cu/Al<sub>2</sub>O<sub>3</sub> catalyst at 773 K for 5 h in flowing air resulted in both the disappearance and an increase in the intensity of the XRD peaks based on CuO (Fig. 7(c)). From these XRD data, the active Cu species is thought to irreversibly convert to inactive Cu species during the benzene oxidation, and the deactivated Cu species will be reactivated through the calcination treatment, as shown in Fig. 6.

To confirm that the precursors of the Cu species based on the XRD peak at  $2\theta = 23^{\circ}$  are related to the active species for phenol formation, the XRD measurement of the used Cu/Al<sub>2</sub>O<sub>3</sub> catalysts prepared in aqueous solution with various acetic acid concentrations was attempted. The height of the XRD peak at  $2\theta = 23^{\circ}$ , together with the yield of phenol, was plotted against the volumetric concentration of acetic acid (Fig. 9). A correlation between the yield of phenol and the intensity of the XRD peak at  $2\theta = 23^{\circ}$  was observed against the volumetric concentration of acetic acid. Thus, the deactivated Cu species based on the XRD peak at  $2\theta =$  $23^{\circ}$  will be formed via the active Cu species for phenol formation, although the composition and the structure of the deactivated Cu species are yet unknown at the present stage.

# 3.4. Hydrogen peroxide formation from an aqueous solution of $Cu^{2+}$ and ascorbic acid in air and the activity for phenol formation

Hydrogen peroxide accumulated during the liquid-phase oxidation of benzene by Cu supported MCM-41 (Cu/MCM-41) catalyst using ascorbic acid as a reducing reagent was



Fig. 9. Dependence of concentration of acetic acid on both the yield of phenol and intensity of the XRD peak at  $2\theta = 23^{\circ}$ . Catalyst: 0.4 g of Cu/Al<sub>2</sub>O<sub>3</sub> (Cu = 2 wt.%); benzene: 22.5 mmol; solvent: 20 cm<sup>3</sup> of aqueous acetic acid; O<sub>2</sub>: 0.1 MPa; ascorbic acid: 4 mmol; reaction temperature: 303 K; reaction time: 24 h. (•) Yield of phenol, (□) intensity of XRD peak at  $2\theta = 23^{\circ}$ .



Fig. 10. Electronic absorption spectra of  $H_2O_2$  generated from aqueous solution containing both  $Cu^{2+}$  and ascorbic acid. (a) Aqueous solution containing both Cu acetate  $(2.2 \times 10^{-5} \text{ mol/l})$  and ascorbic acid  $(8.0 \times 10^{-4} \text{ mol/l})$ , (b) aqueous solution of  $H_2O_2$  ( $8.8 \times 10^{-4} \text{ mol/l}$ ), (c) aqueous solution of ascorbic acid ( $8.0 \times 10^{-4} \text{ mol/l}$ ).

quantitatively analyzed by conventional iodometry [18]. To directly observe whether  $H_2O_2$  is formed in the presence of oxygen (air), ascorbic acid, and the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst, the UV-Vis spectrum of the aqueous solution including Cu(II) acetate and ascorbic acid was measured, in addition to those of aqueous solutions of only ascorbic acid and H<sub>2</sub>O<sub>2</sub> (Fig. 10). Copper(II) acetate was utilized, in place of the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst, because the Cu<sup>2+</sup> species leached from the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst, together with the Cu species supported on the catalyst, are considered to play a role in H<sub>2</sub>O<sub>2</sub> formation. An absorption peak was detected at around 200 nm (Fig. 10(a)), the peak of which is identical of that of authentic aqueous  $H_2O_2$  (Fig. 10(b)), when the aqueous solutions of the  $Cu^{2+}$  and ascorbic acid were mixed in air. Benzene oxidation was attempted under a variety of conditions with and without H<sub>2</sub>O<sub>2</sub> to investigate the role of the reducing reagent (ascorbic acid) and the oxidant for phenol formation (Table 3). In the absence of  $H_2O_2$ , the presence

Table 3 Influence of oxidant and reducing reagent on the phenol formation<sup>a</sup>

Run	H <sub>2</sub> O <sub>2</sub> (mmol)	Ascorbic acid (mmol)	Atmosphere	Yield of phenol (%)
1	0	0	N <sub>2</sub>	0
2	0	0	$O_2$	0
3	0	4	O <sub>2</sub>	2.5
4	0	4	$N_2$	0
5	9.6	4	$O_2$	1.2
6	9.6	0	$N_2$	0
7	9.6	0	$O_2$	0.2

<sup>a</sup> *Reaction conditions*: catalyst,  $Cu/Al_2O_3$  (Cu = 2 wt.%), 0.4 g; benzene, 22.5 mmol; solvent, 20 ml of aqueous acetic acid (80 vol.%); reaction pressure, 0.1 MPa; reaction temperature, 303 K; reaction time, 24 h. of Cu species, ascorbic acid and  $O_2$ , followed by the formation of  $H_2O_2$  as described previously (Fig. 10), are essential to phenol formation (Run 3). Contrary to our expectation, no phenol was detected in the presence of  $H_2O_2$  and in the absence of both ascorbic acid and  $O_2$  under the present reaction condition (Run 6). Only small amount of phenol was produced in the presence of both  $H_2O_2$  and  $O_2$  and in the absence of ascorbic acid (Run 7). From the results of Table 3, the  $O_2$  and ascorbic acid may be necessary for the generation of hydroxyl radical from hydrogen peroxide, though we do not have the mechanism of the formation of hydroxyl radical.

#### 4. Conclusions

An aqueous solvent with high acetic acid concentration was confirmed to be an effective medium for the benzene oxidation catalyzed by a supported Cu catalyst. The benefits of both a comparatively high yield of phenol and a low apparent Cu leaching was simultaneously obtained using a Cu catalyst impregnated on  $Al_2O_3$  (Cu/Al\_2O\_3), as well as a CuO-Al<sub>2</sub>O<sub>3</sub> catalyst prepared by a co-precipitation method reported previously [20], in the aqueous solvent with high acetic acid concentrations (around 70-80 vol.%). The apparent Cu leaching from the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst during the benzene oxidation dramatically decreased using the aqueous solvent with acetic acid concentrations of more than around 70 vol.%. However, too high a concentration of acetic acid (more than 80 vol.%) caused a sharp decrease in the yield of phenol. The yield of phenol had a maximum value at an amount of the supported Cu of ca. 2 wt.%, and a further increase in the amount of the supported Cu caused a decrease in the yield of phenol. The aggregated Cu species on the Cu/Al<sub>2</sub>O<sub>3</sub> catalyst observed from the ESR spectra was suggested to inhibit the formation of phenol. The phenol yield increased with an increase in the amount of ascorbic acid and passed though a maximum value using both the Cu/Al<sub>2</sub>O<sub>3</sub> and CuO-Al<sub>2</sub>O<sub>3</sub> catalysts in the aqueous solvent with 80 vol.% acetic acid. The formation of hydrogen peroxide was observed in the electronic absorption spectra of the aqueous solution in the presence of  $Cu^{2+}$  ion, ascorbic acid, and O<sub>2</sub>. The used Cu/Al<sub>2</sub>O<sub>3</sub> catalyst had a new XRD peak at  $2\theta = 23^{\circ}$ . Both the peak intensity at  $2\theta = 23^{\circ}$  and the yield of phenol had a similar dependence on the volumetric concentration of acetic acid in the aqueous solvent. The deactivated Cu species based on the XRD peak at  $2\theta = 23^{\circ}$  will be thus formed via the active Cu species for phenol formation. The calcinations of the used Cu/Al<sub>2</sub>O<sub>3</sub> catalyst caused the disappearance of the XRD peak at  $2\theta = 23^{\circ}$  and the recovery of the catalytic activity for the phenol formation.

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